

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re the Application of: **Miwa KOZAWA et al.**

Group Art Unit: **1756**

Application Number: **10/720,097**

Examiner: **Daborah Chacko Davis**

Filed: **November 25, 2003**

Confirmation Number: **4454**

For: **PROCESS FOR FORMING RESIST PATTERN, SEMICONDUCTOR  
DEVICE AND FABRICATION THEREOF**

Attorney Docket Number: **032132**

Customer Number: **38834**

**PETITION FOR EXTENSION OF TIME**

Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

January 7, 2008

Sir:

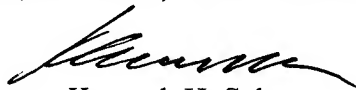
Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated August 8, 2007 for two month(s) from November 8, 2007 to January 8, 2008.

Attached please find a check in the amount of \$460.00 for the cost of the extension.

If any additional fees are due in connection with this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

**WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP**



Kenneth H. Salen  
Attorney for Applicants  
Registration No. 43,077  
Telephone: (202) 822-1100  
Facsimile: (202) 822-1111

KHS/rf